

## TRANSMITTAL

Electronic Version v1.1

Stylesheet Version v1.1.0

<b>Title of Invention</b>	PT COATING INITIATED BY INDIRECT ELECTRON BEAM FOR RESIST CONTACT HOLE METROLOGY	
Application Number :		
Date :		
First Named Applicant:	Wei Lu	
Confirmation Number:		
Attorney Docket Number:	FIS920030308	
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Documents being submitted:	Files
us-fee-sheet	FIS920030308-usfees.xml us-fee-sheet.xsl us-fee-sheet.dtd
us-ids	FIS920030308-usidst.xml us-ids.dtd us-ids.xsl
us-assignment	FIS920030308-usassn.xml us-assignment.xsl us-assignment.dtd FIS920030308assign1.tif FIS920030308assign2.tif
us-request	FIS920030308-usrequ.xml us-request.dtd us-request.xsl
application-body	FIS920030308-trans.xml us-application-body.xsl application-body.dtd wipo.ent mathml2.dtd mathml2-qname-1.mod isoamsa.ent isoamsb.ent isoamsc.ent isoamsn.ent isoamso.ent isoamsr.ent isogr3.ent isomfrk.ent isomopf.ent isomscr.ent isotech.ent isobox.ent isocyr1.ent isocyr2.ent isodia.ent isolat1.ent isolat2.ent isonum.ent isopub.ent mmlextra.ent mmlalias.ent soextblx.dtd FIS920030308dwg1.tif FIS920030308dwg2.tif FIS920030308dwg3.tif FIS920030308dwg4.tif
us-declaration	FIS920030308dec1.tif
<b>Comments</b>	
Assignee Name: International Business Machines Corporation, Assignee Residence: Armonk, NY 10504	